
*Simulation of Multi-Technology Micro
and Nano Systems*

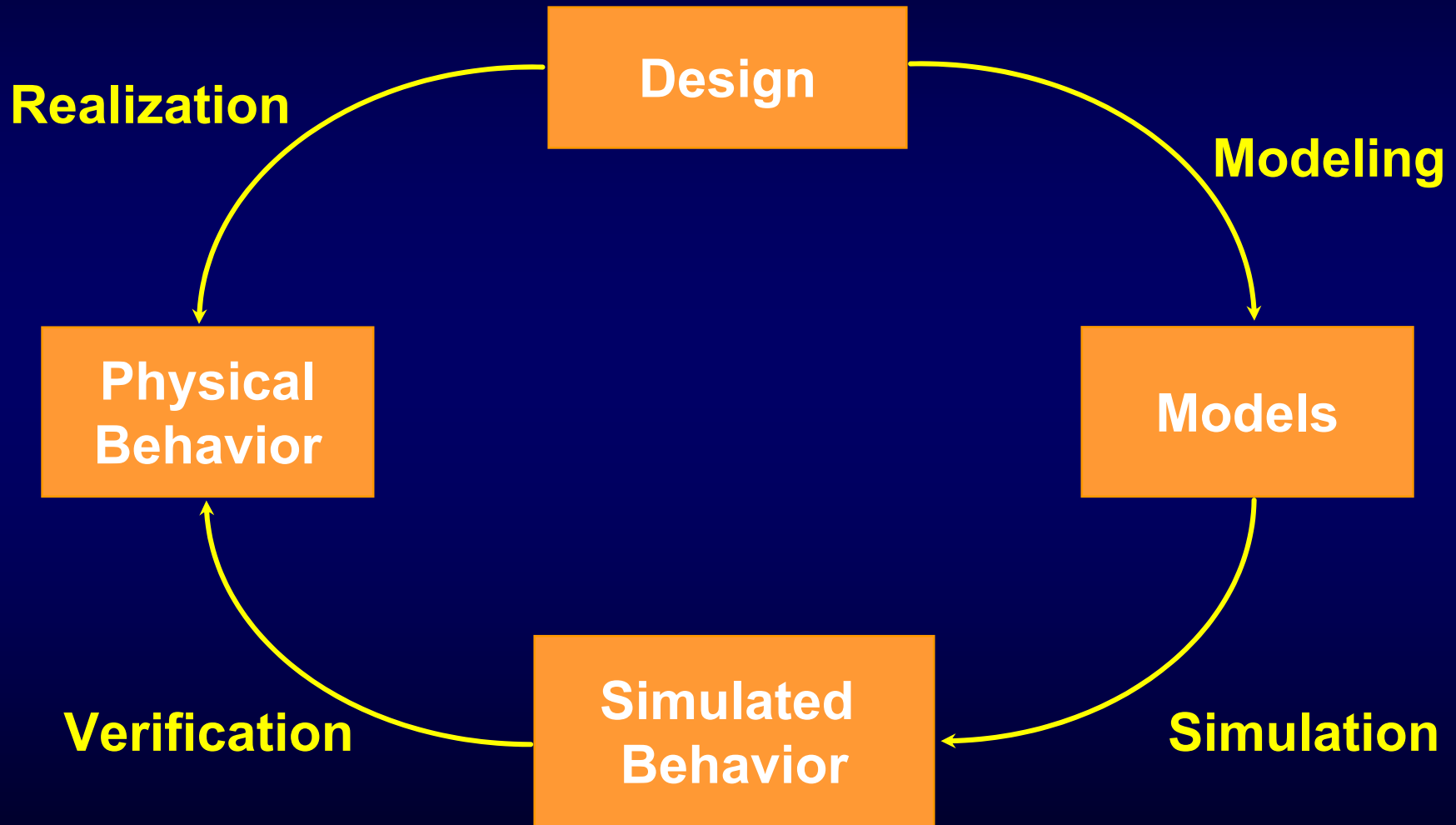
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Outline

- **Introduction**
- **Coupled circuit/device simulation**
- **Advantages and applications to integrated circuits**
- **Examples of simulating microsystems**
 - Microfluidic flow
 - Electroosmotic flow
 - Piezoelectric micropower generator
 - Phase noise of MEMS RF VCOs

Role of Modeling in Design



The Modeling Hierarchy

Speed



Accuracy

High-level
models

Lumped-
element
models

Compact
models

Numerical
models

VHDL-AMS

RLC

BSIM3

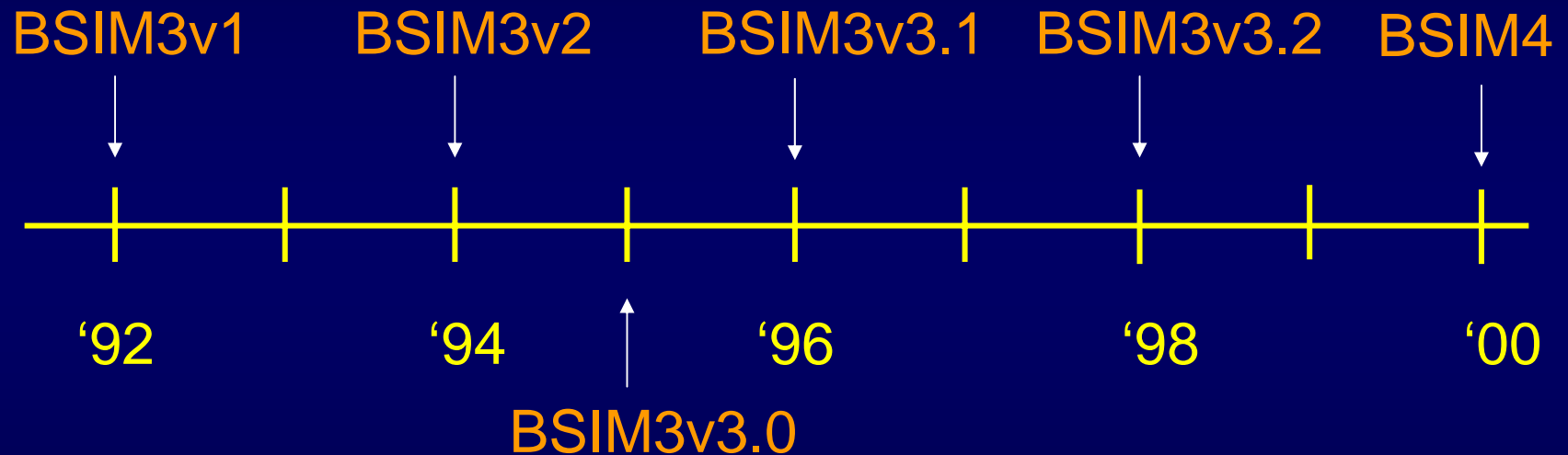
PISCES

Verilog-A

EKV

Medici

A Case Study - BSIM3 MOSFET Model



- **Compact model development, implementation and validation takes several years**

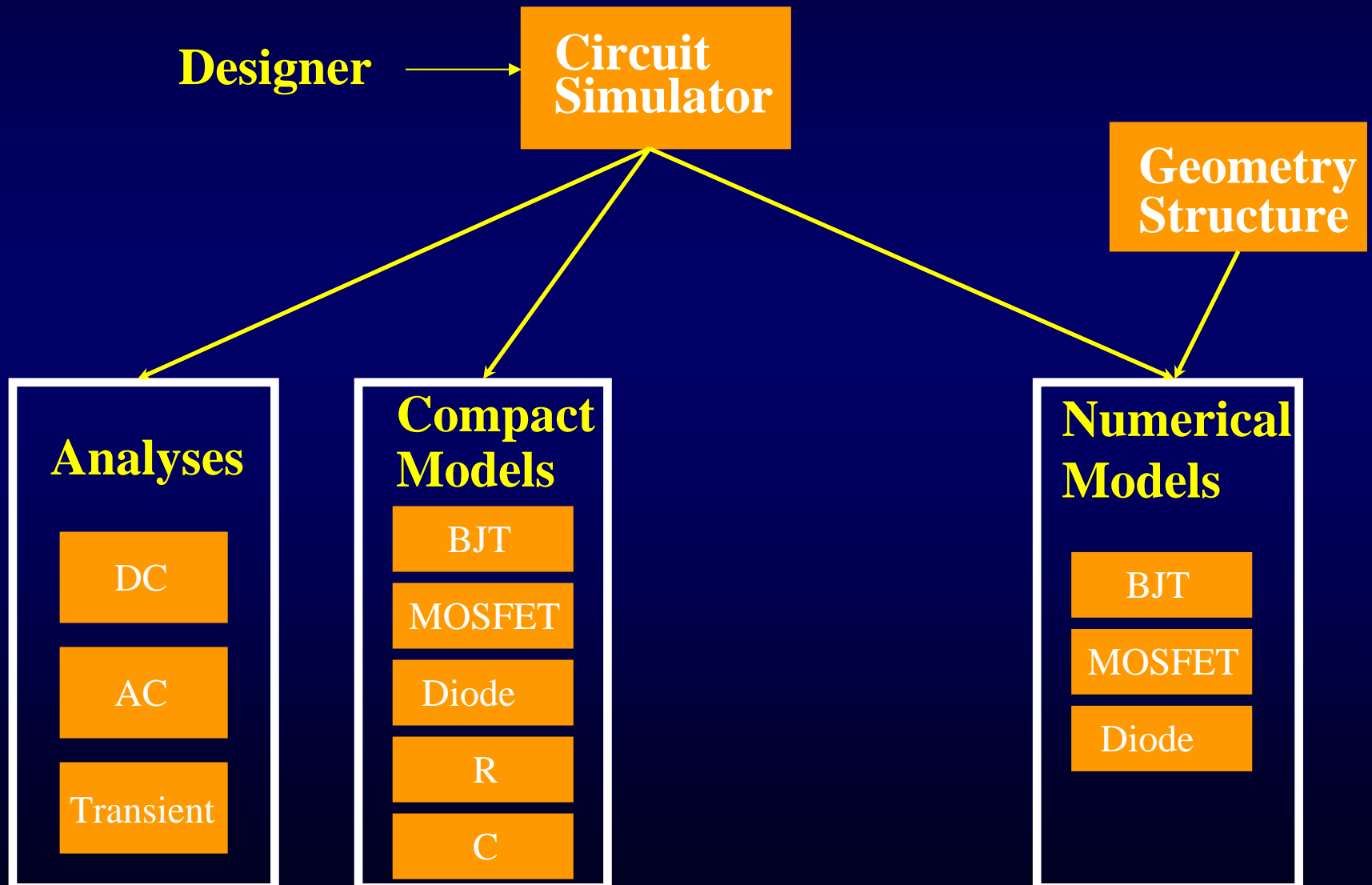
Circuit/Device Simulation

- **Circuit simulation**
 - Compact models used: inaccurate under certain conditions
 - + Simulation of multiple devices in a circuit
- **Device simulation**
 - + Based on device physics: accurate
 - Simulation of a single device, no circuit embedding
- **Coupled circuit/device simulation**
 - + Accurate
 - + Simulation of complete systems

Coupled Circuit/Device Simulator

- **Compact models for electronic components (BJTs, MOSFETs, ...)**
- **Accurate numerical models for various components**
- **Analysis capabilities supported by the circuit simulator**

Coupled Circuit/Device Simulator

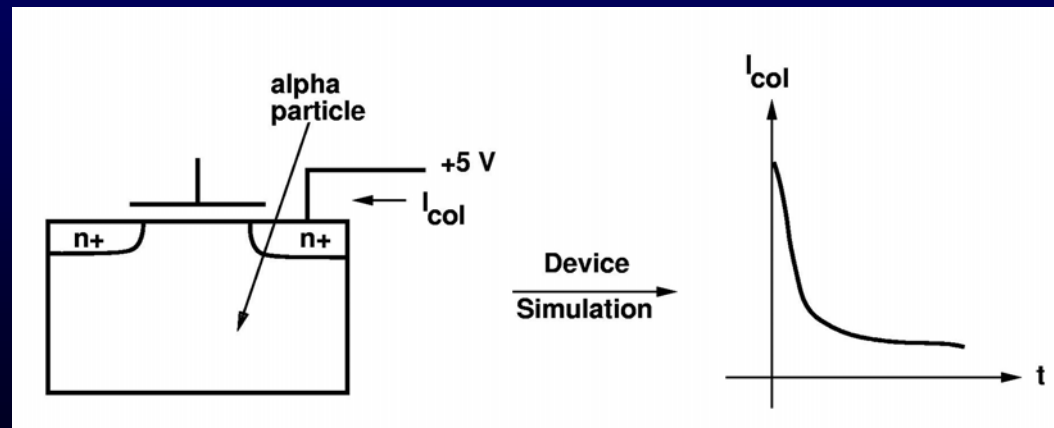
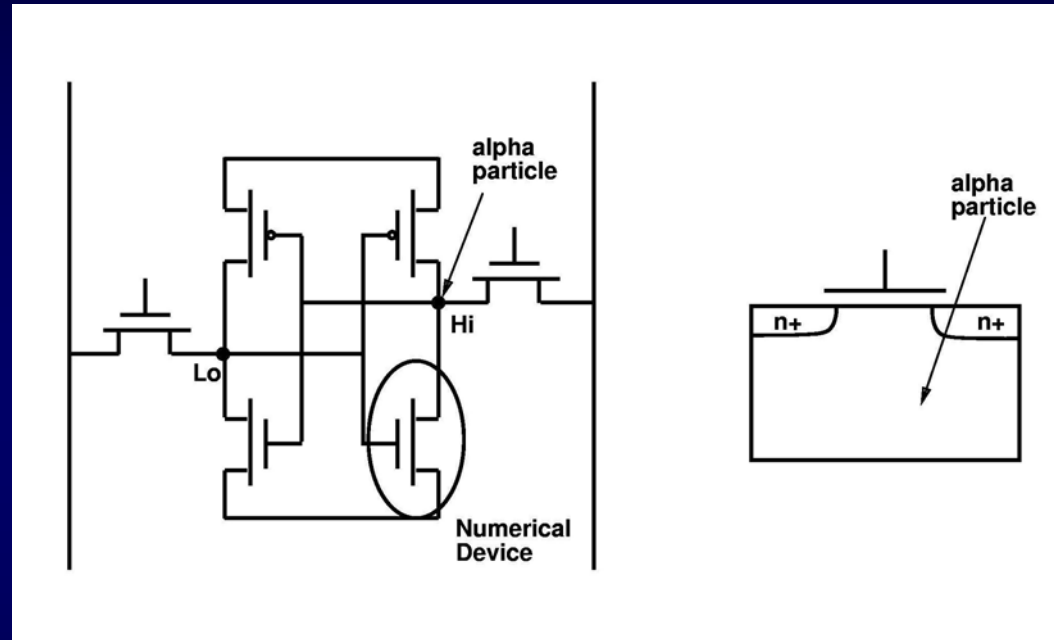


Advantages

- **Simulate critical devices at the device level within a circuit**
 - Solve partial differential equations describing devices coupled to a circuit simulator
- **Predict performance of circuits in absence of compact models for devices**
- **Evaluate influence of process variations on circuit performance**

Application Example - Single Event Upset in SRAM Cell

- **Critical transistor modeled at the physical (numerical) level**
- **Other transistors modeled with compact models**
- **Alpha particle strike simulated with circuit boundary conditions**



Simulation of Micro/Nano Systems

- **Micro/nano device simulation**
 - Finite-element methods (FEM)
 - Fast integral methods
- **Simulation of complete systems**
 - Lumped equivalent circuit representations
 - Macromodels derived from FEM analysis
 - Analog hardware description language (AHDL) descriptions

Limitations of High-Level Models

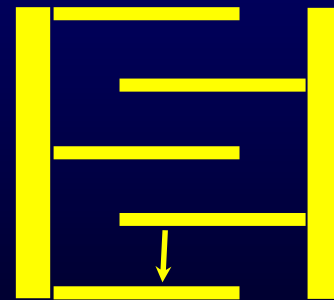
- **Typically derived for small-signal conditions**
- **Not suitable for systems with feedback**
- **Cannot predict behavior outside range**

Beam bending



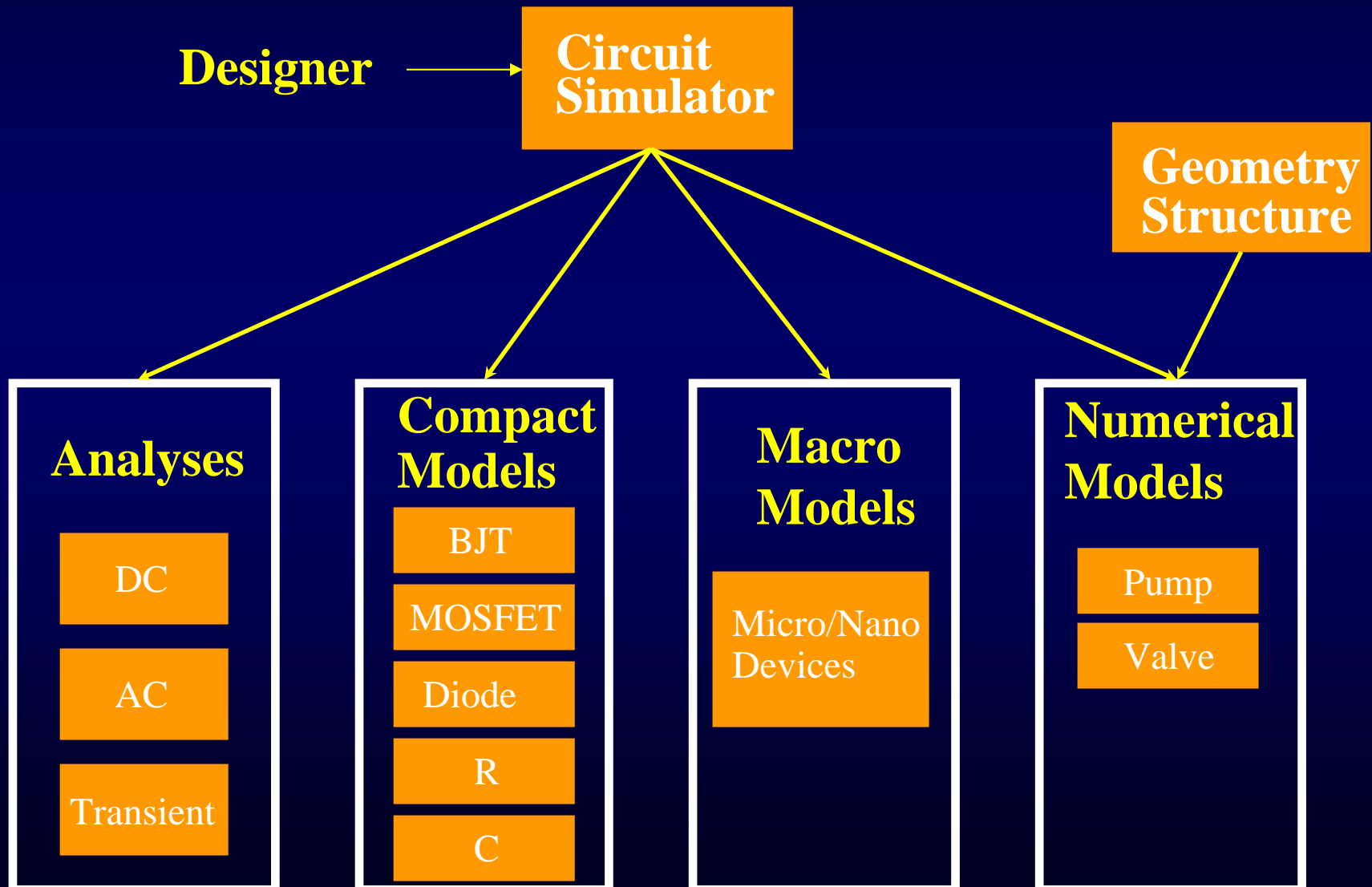
reach substrate

Comb structure



reach limit stops

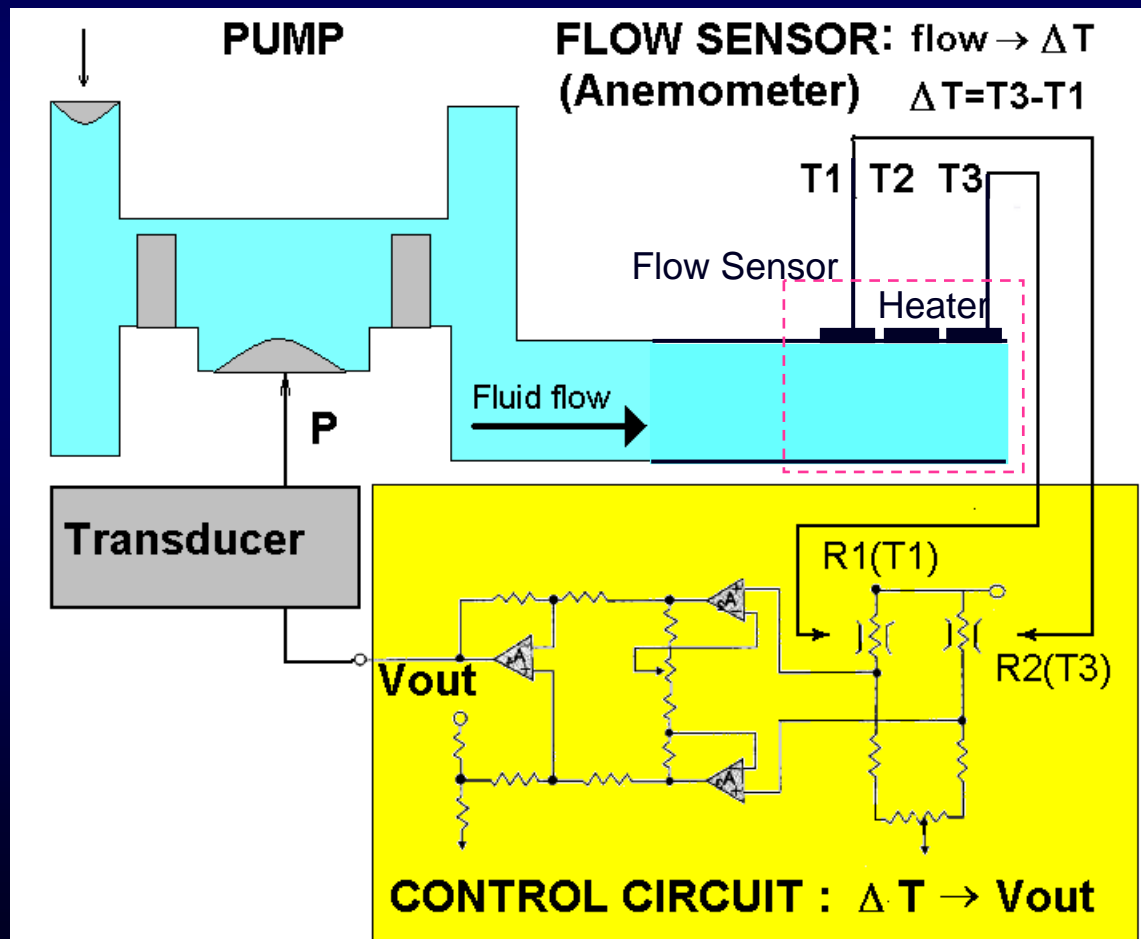
Coupled Circuit/Micro(Nano) Device Simulator



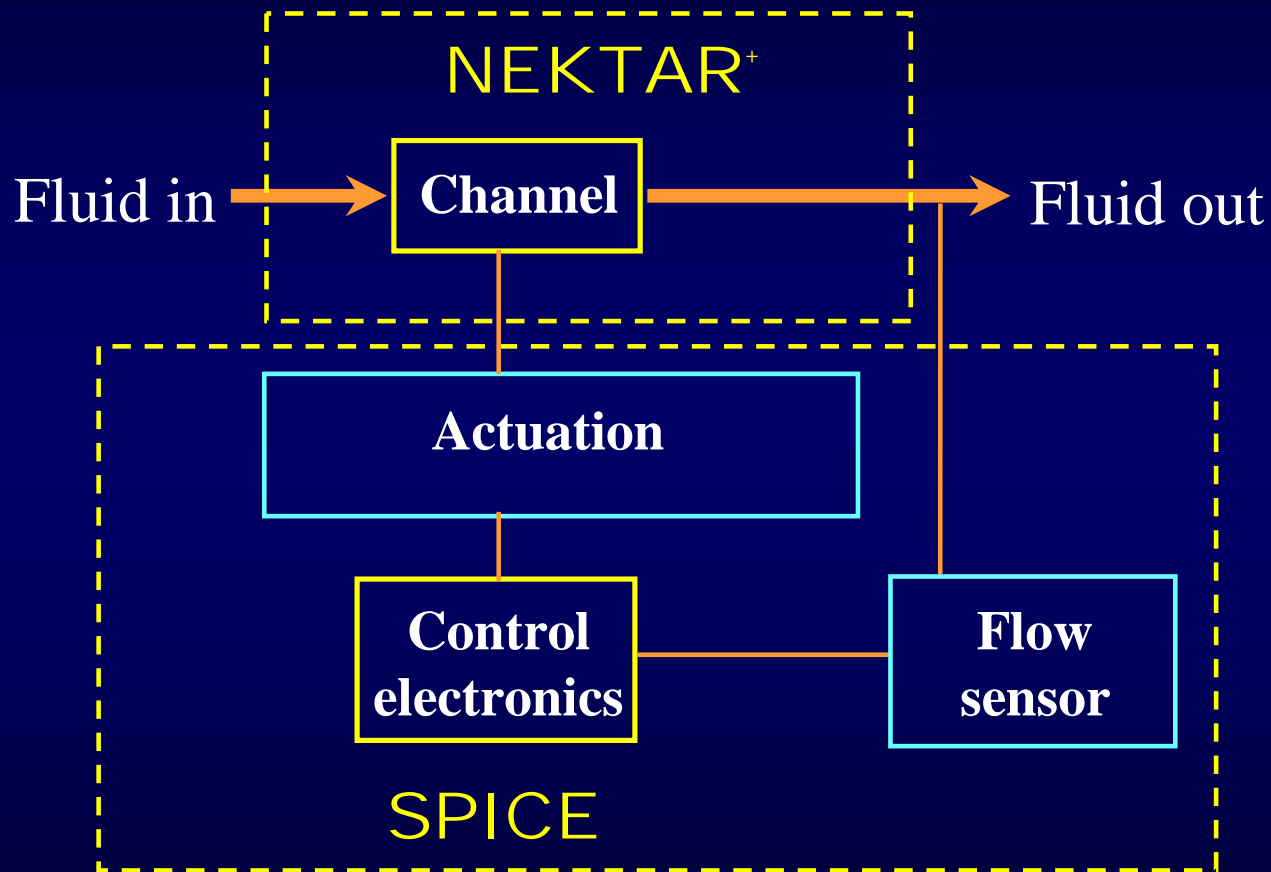
Microfluidic System

Micro Fluidic Simulation Example

- Constant flow system



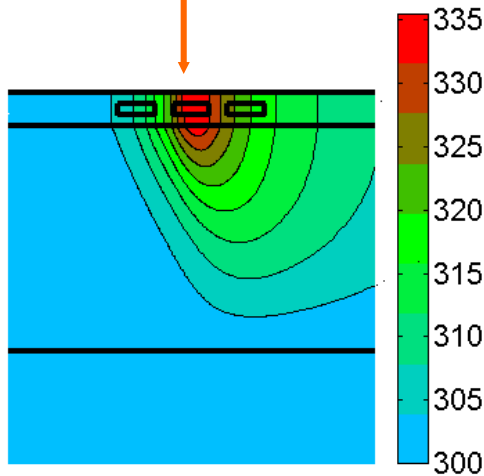
Simulator Interaction



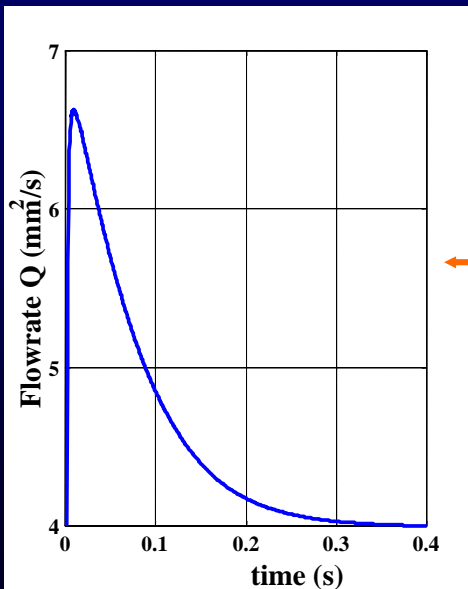
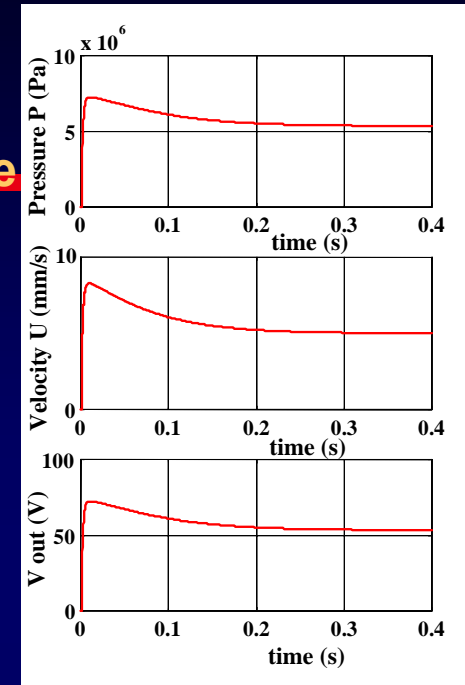
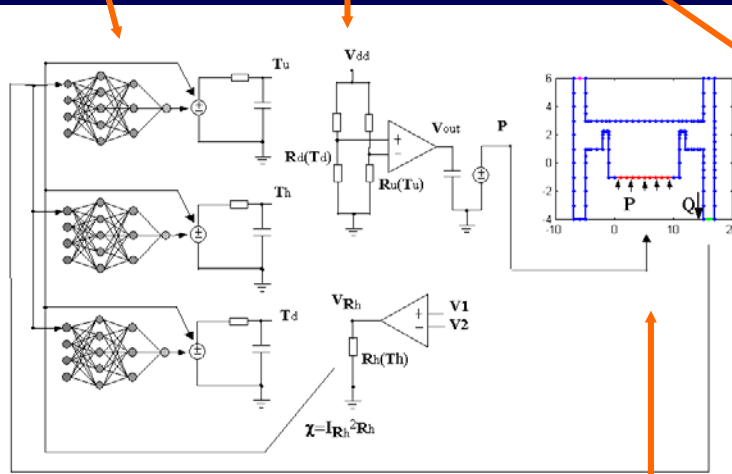
⁺ R. M. Kirby, et al., "The NEKTAR code: Dynamic simulations without remeshing," *Proc. ICCT*, 1999.

Coupled System Simulation: 4 Physical Domains

Flow sensor: Flow to Temperature (thermal domain)

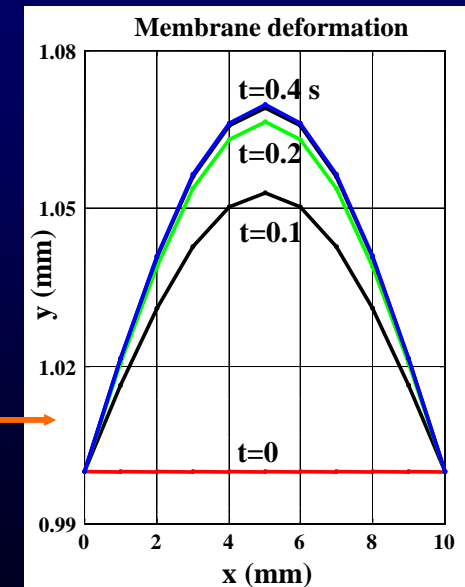


Circuit: Temperature to Voltage (electrical domain)



Micropump: Displacement to Flow (fluid domain)

Piezo-actuator: Voltage to Displacement (structure domain)



Summary of Microfluidic System Simulator

- **Integrated simulator allows simulation of complete system with integrated thermal, flow, structural, and electric domains**
- **Fluid solver determines overall simulation performance**

R. M. Kirby, et al., "An integrated simulator for coupled domain problems in MEMS," *JMEMS*, pp. 379-391, Sept. 2001.

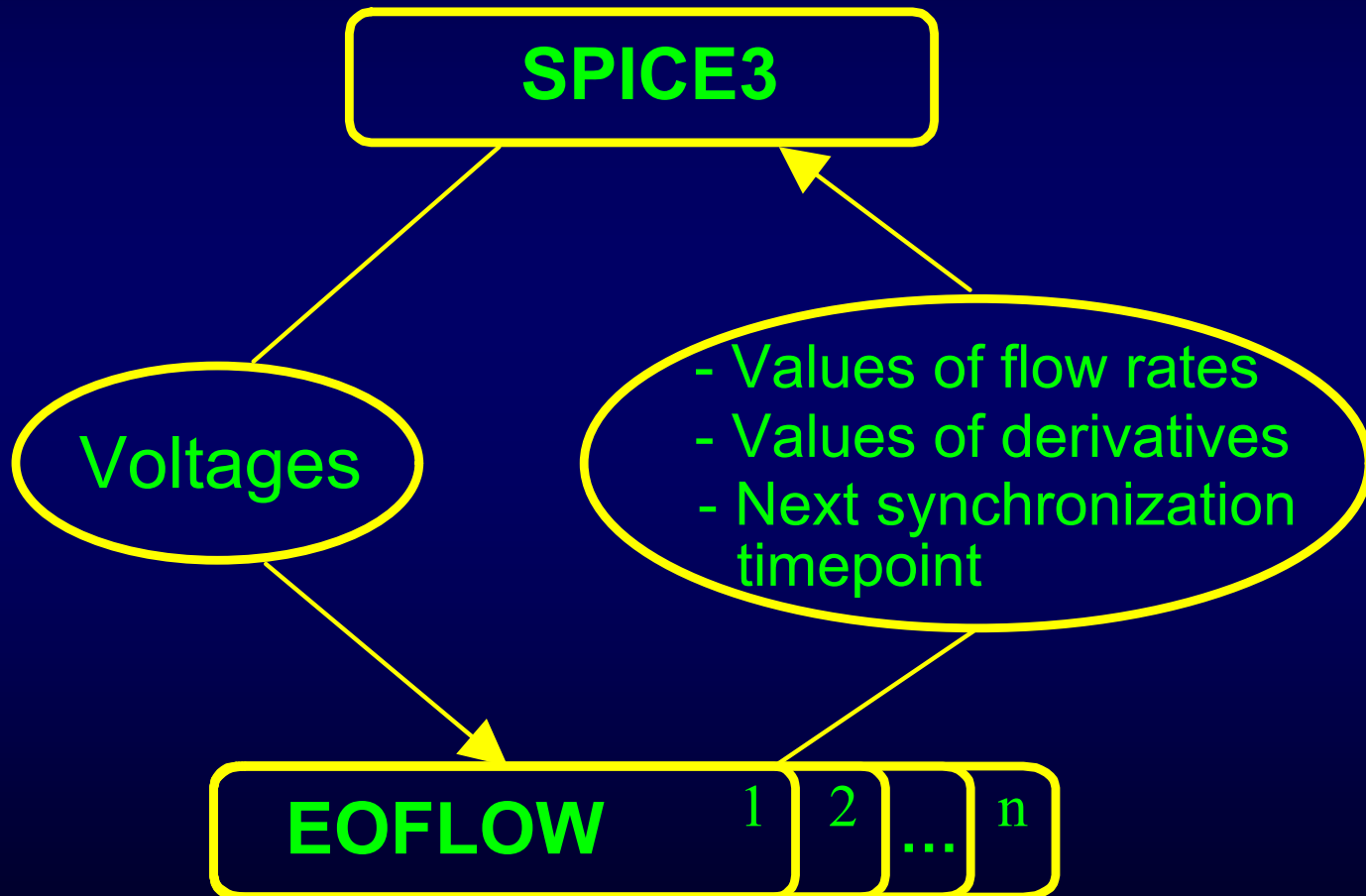
Electroosmotic Flow

Simulation of Electroosmotic Flow

- **An electroosmotic flow channel has fluidic and electronic components**
- **Physical model generation for fluidic channels requires significant time**
 - SPICE3 for circuit-level simulation
 - EOFLOW^{*} for numerical simulation of electroosmotic flow channels

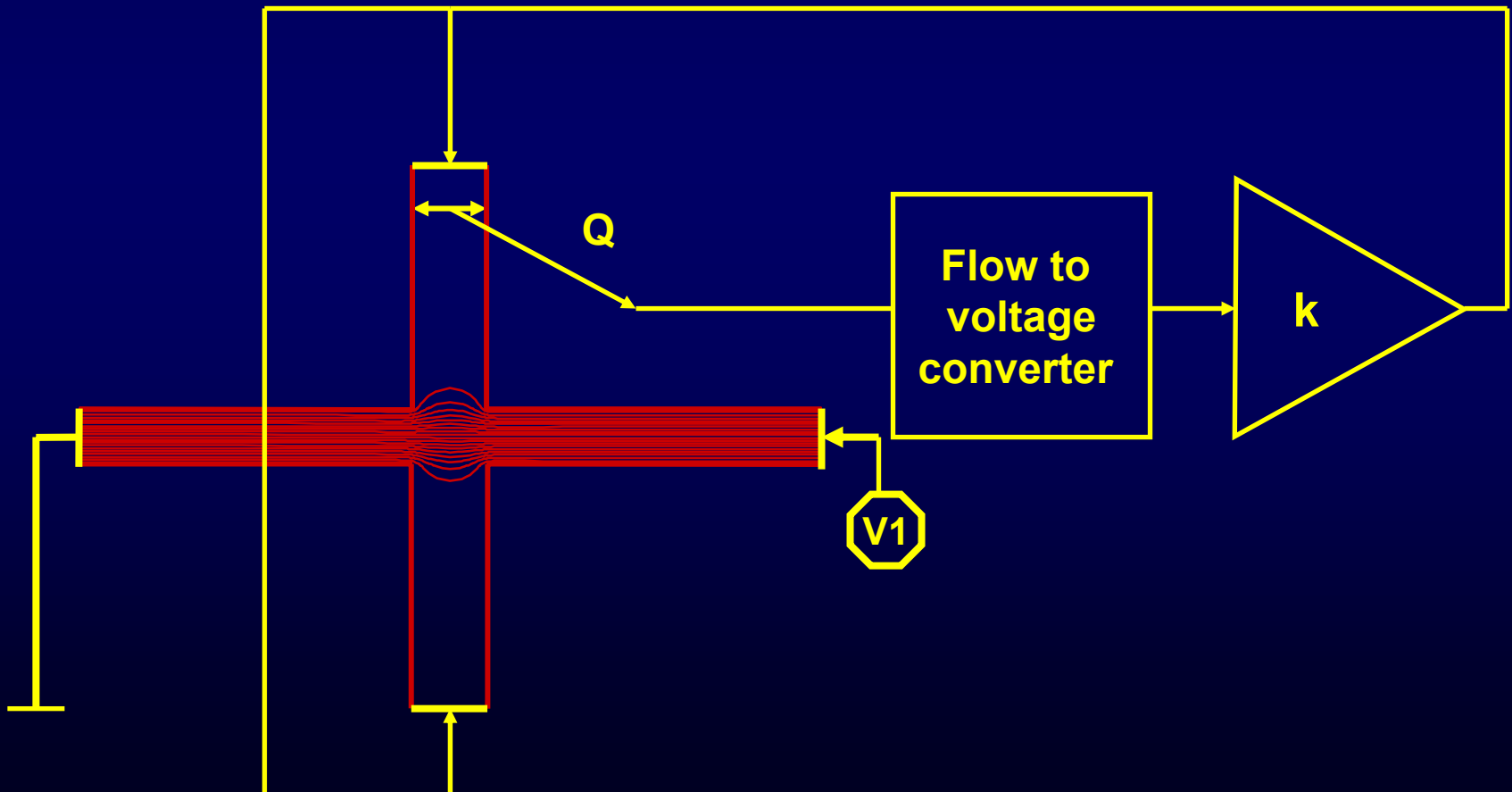
* M. J. Mitchell, et al., “Meshless analysis of steady-state electro-osmotic transport,” *JMEMS*, pp. 435–449, Dec. 2000.

Simulator Interaction

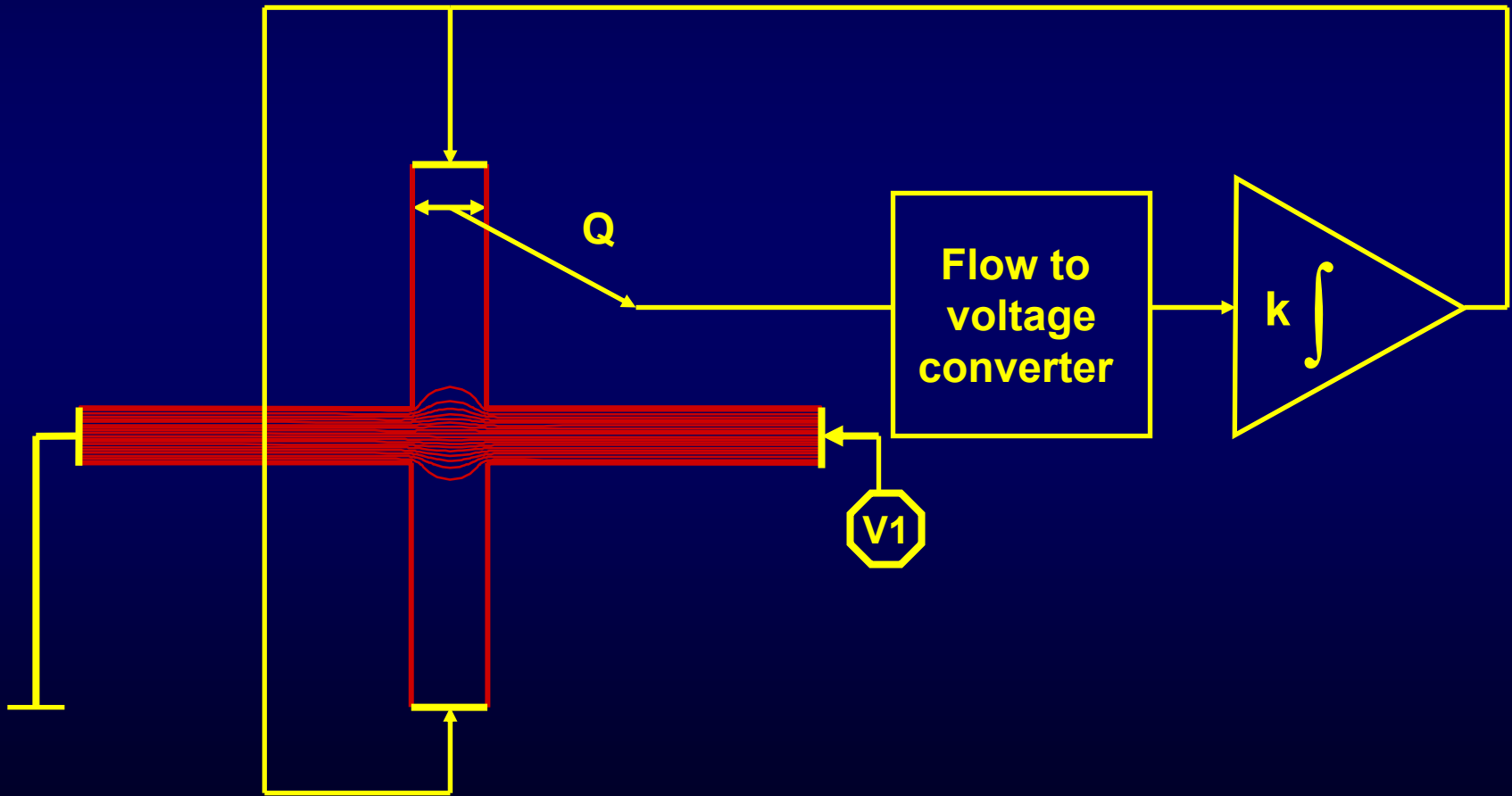


Flow Rate Control System

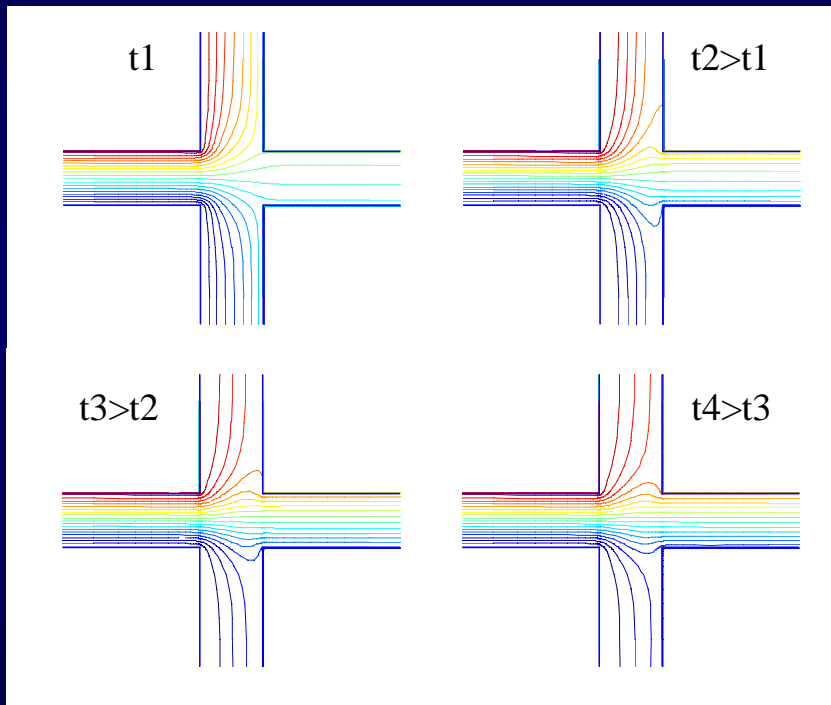
- To avoid flow distortion, vertical velocity must be reduced



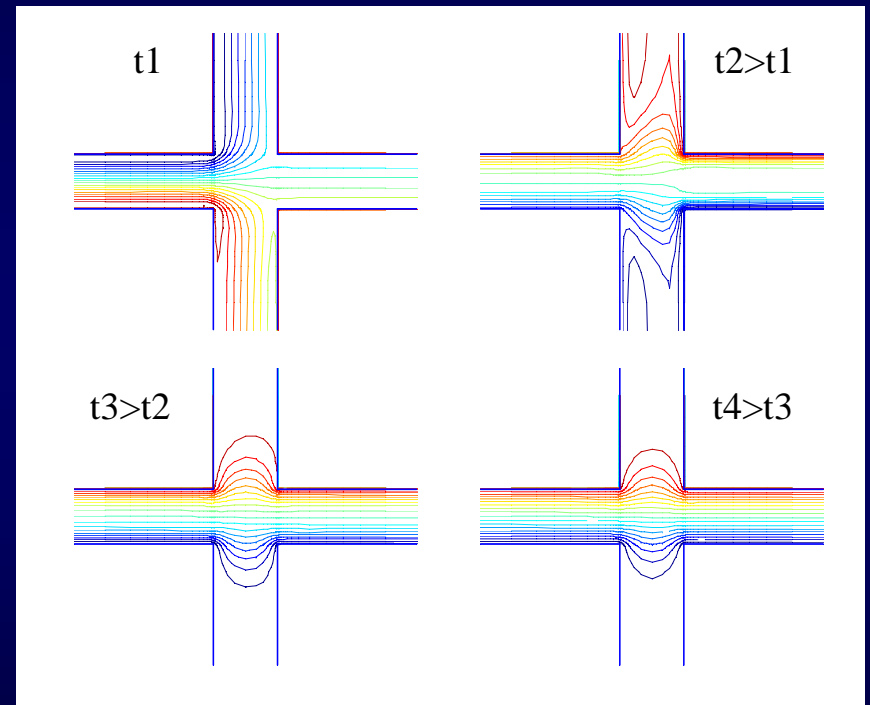
Proportional Integral Control System



Dynamic Behavior of Streamlines for the Electroosmotic System

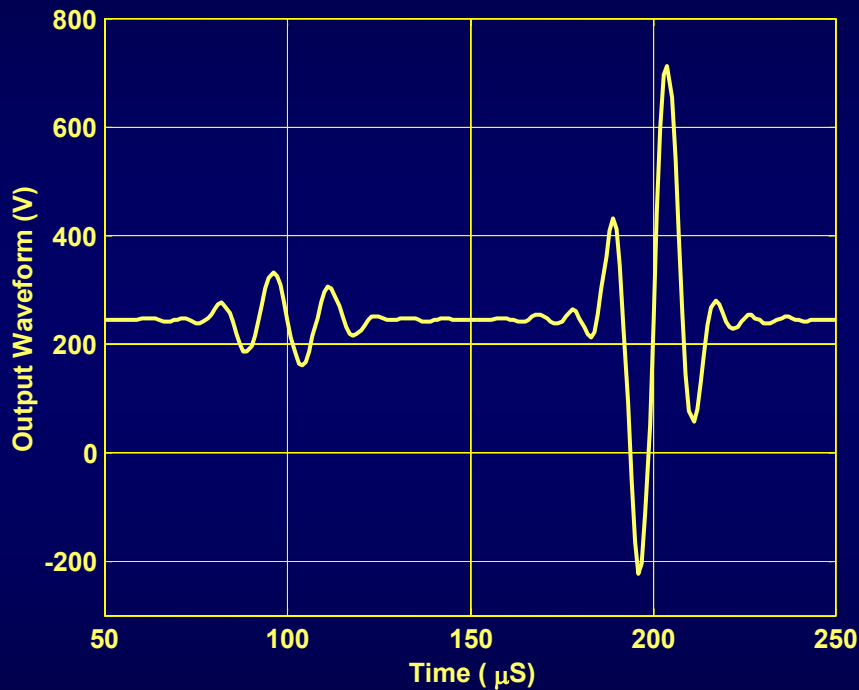


Proportional control

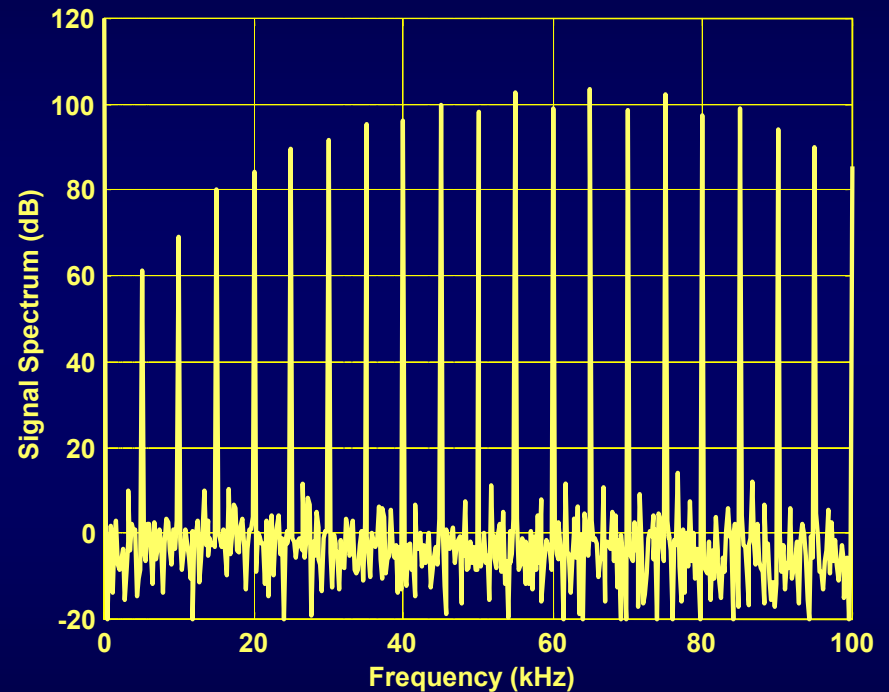


Proportional-integral control

Simulation Results for 10 x 10 Cross Channel Mesh



One period of output signal



Spectrum of output signal

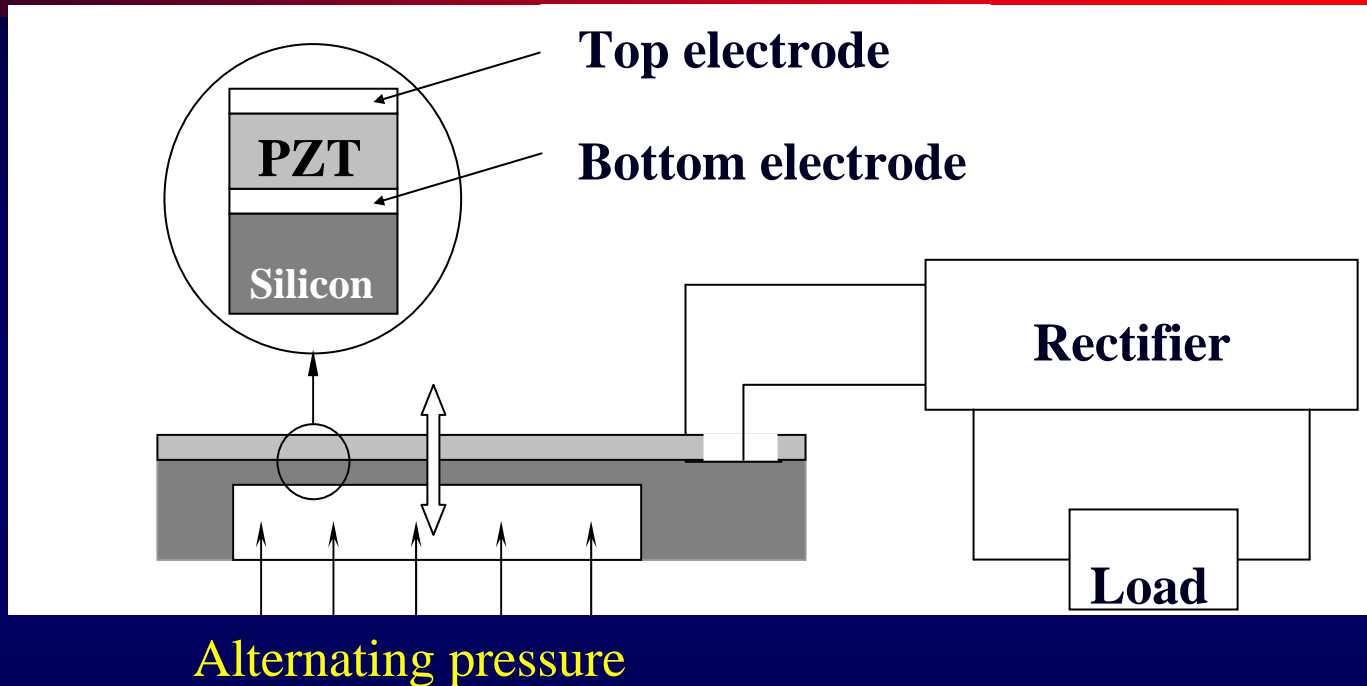
Summary of Electroosmotic Flow Control Simulator

- **Various electronic control options can be evaluated**
 - Proportional-integral control is better than proportional control
- **Simulation of a complex network of interconnected channels possible**

T. Dudar, et al., "Simulation of electronic control in electroosmotic flow channels," *SISPAD 2003*, pp. 235-238, Sept. 2003.

Piezoelectric Micropower Generation System

Piezoelectric Generator



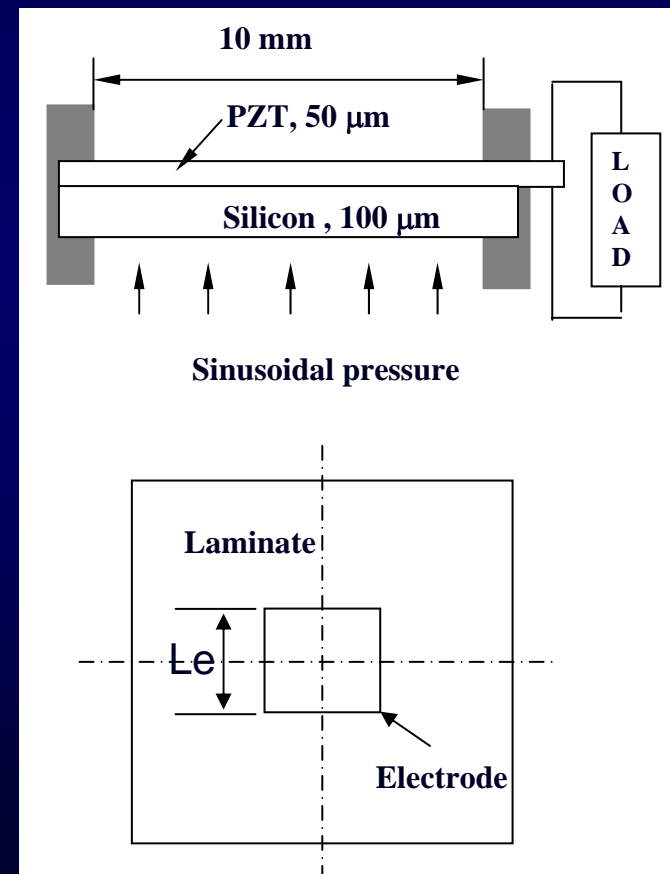
- Mechanically force the membrane to vibrate
- PZT transform mechanical energy into electric energy

C. D. Richard, et al., "MEMS power: The P3 system,"
Proc. IECE2001

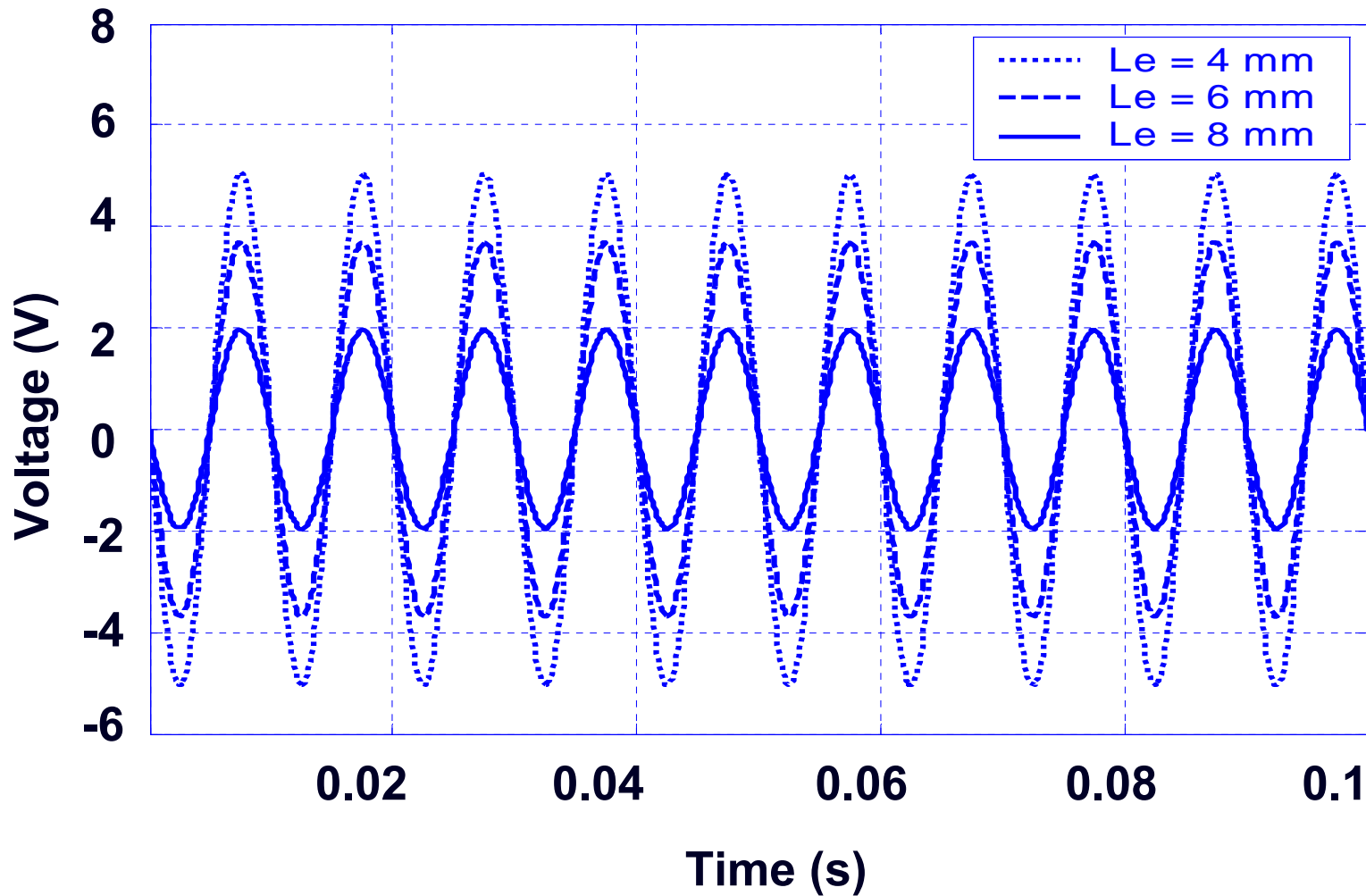
Numerical Example

- The electrode is taken as an equal potential region
- A sinusoidal pressure is applied
- Output voltage depends on electrode length L_e
- Power delivered varies with load

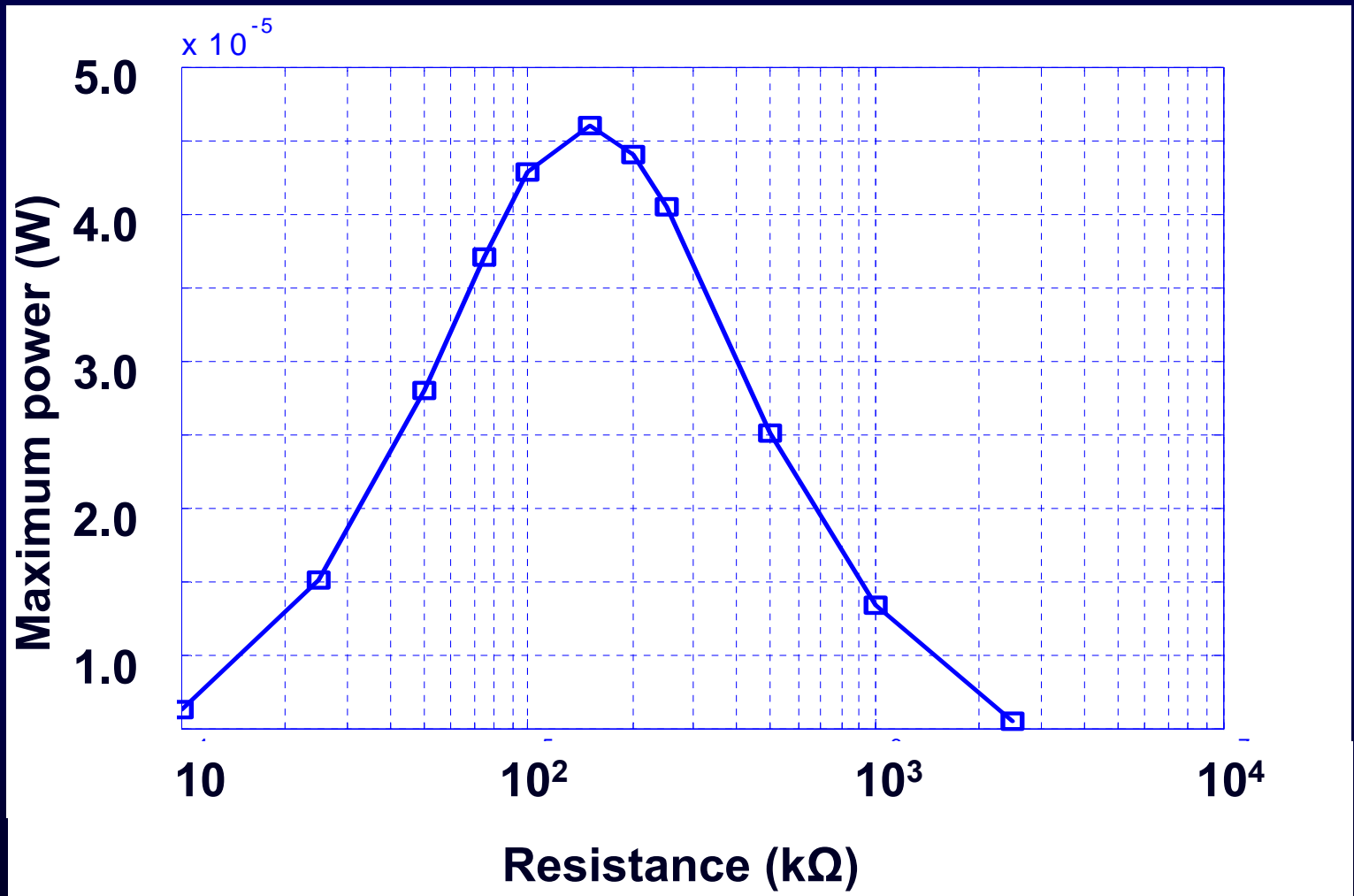
Micro piezogenerator



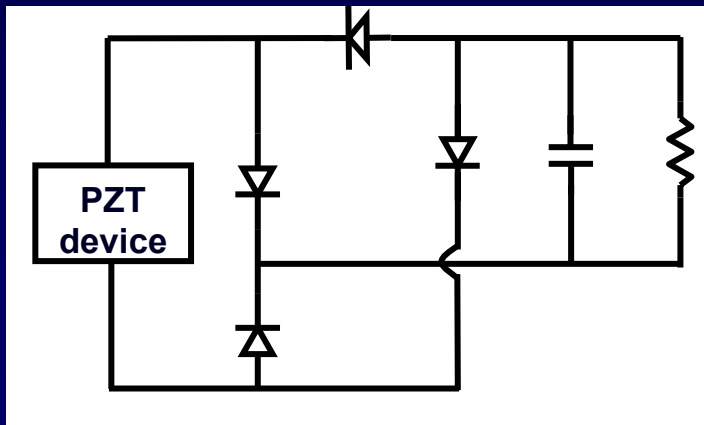
Open Circuit Voltage Decreases With An Increasing Electrode Size



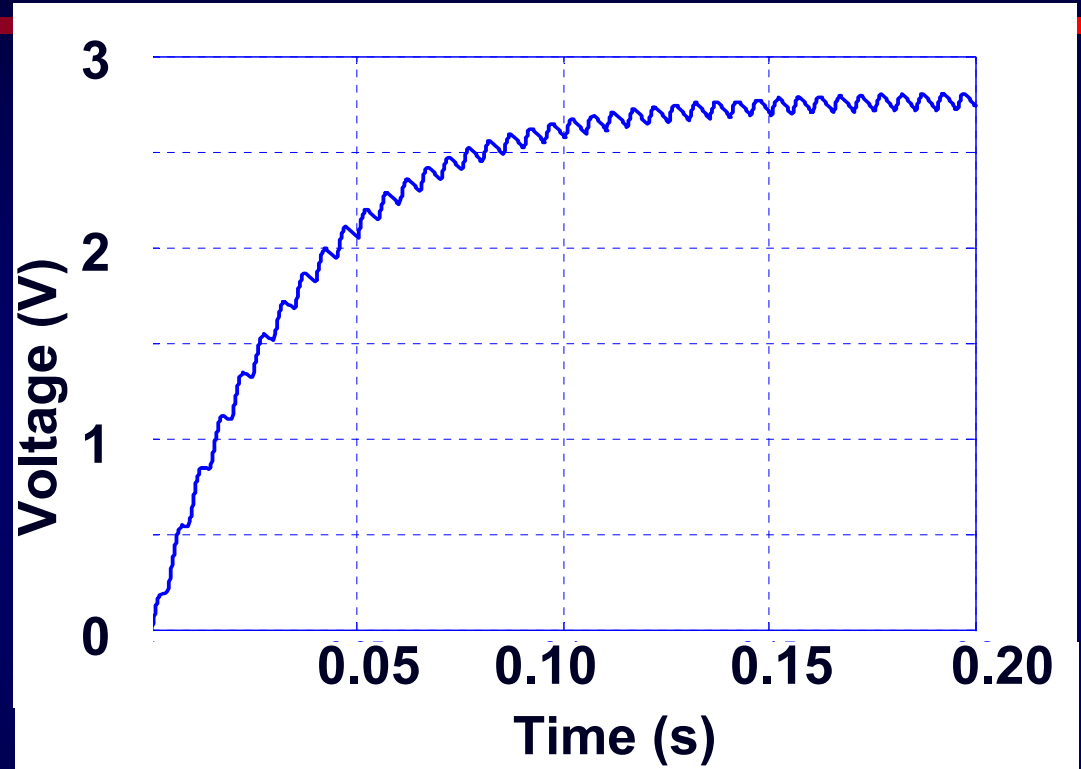
Matching Resistance for maximum power output



A Rectifier Circuit



Circuit Configuration



- The time evolution of the voltage across the load resistor is as expected

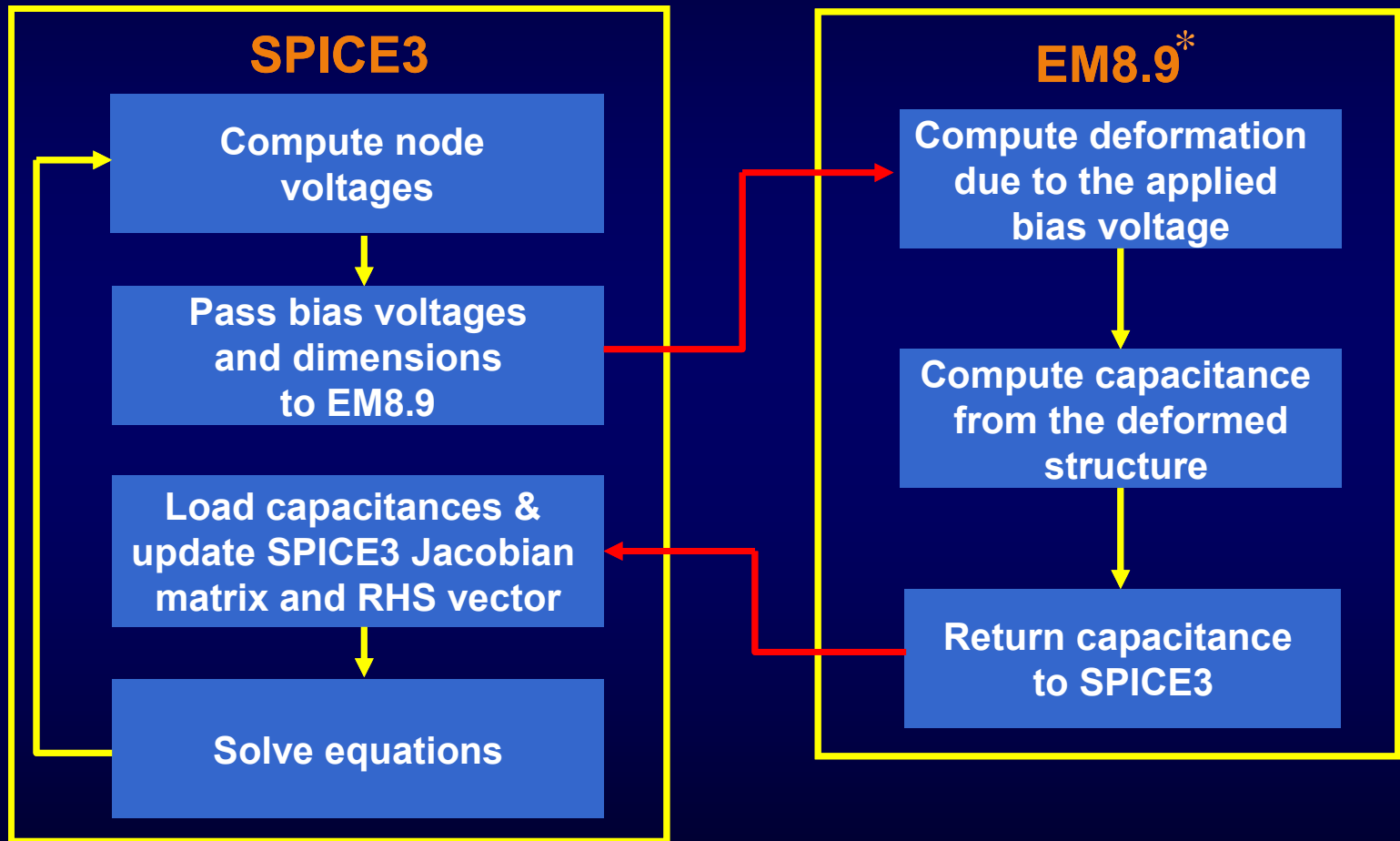
Summary of Piezoelectric Generator Simulator

- **Simulation of coupling piezoelectric devices and complex circuits**
- **Numerical examples demonstrate effectiveness of the coupled simulator**

C. Xu, et al., "Coupled simulation of circuit and piezoelectric laminates," *ISQED 2003*, pp. 369-372, March 2003.

RF MEMS VCOs

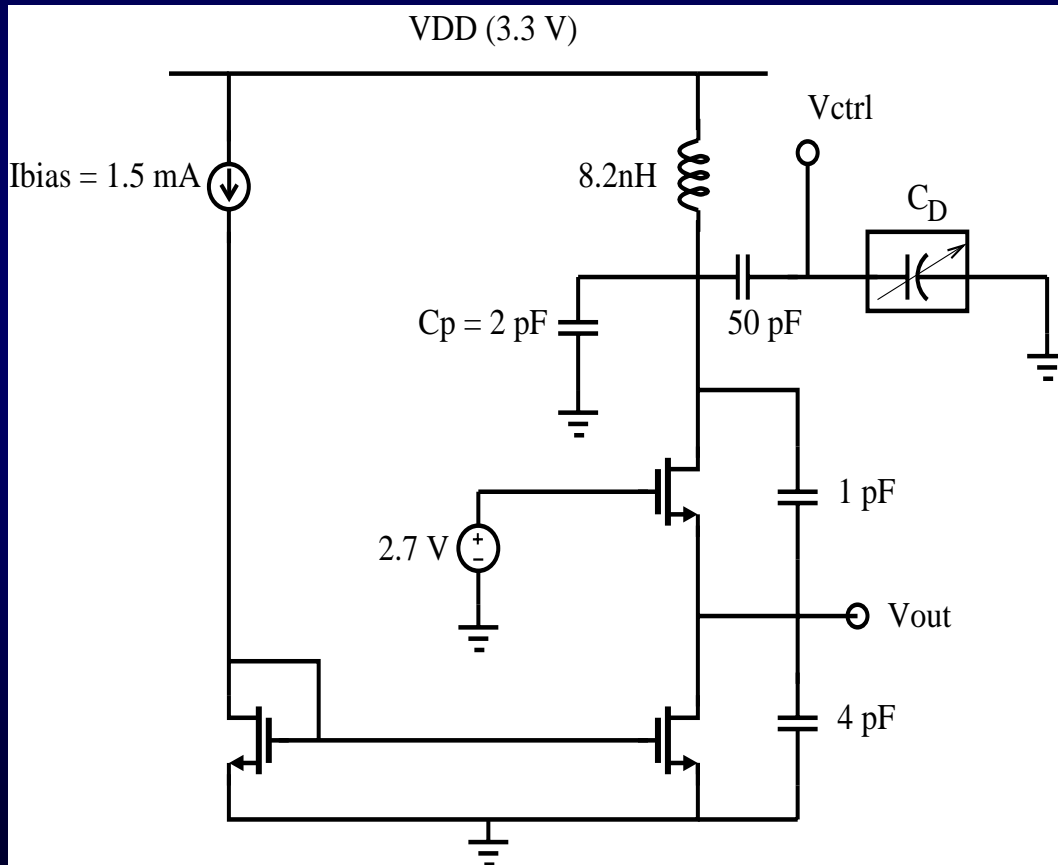
SPICE3 – EM8.9 Integration



* G. Li et al., "Efficient mixed-domain analysis of electrostatic MEMS," *IEEE Trans. CAD*, pp. 1228-1242, Sept. 2003.

800 MHz MEMS VCO

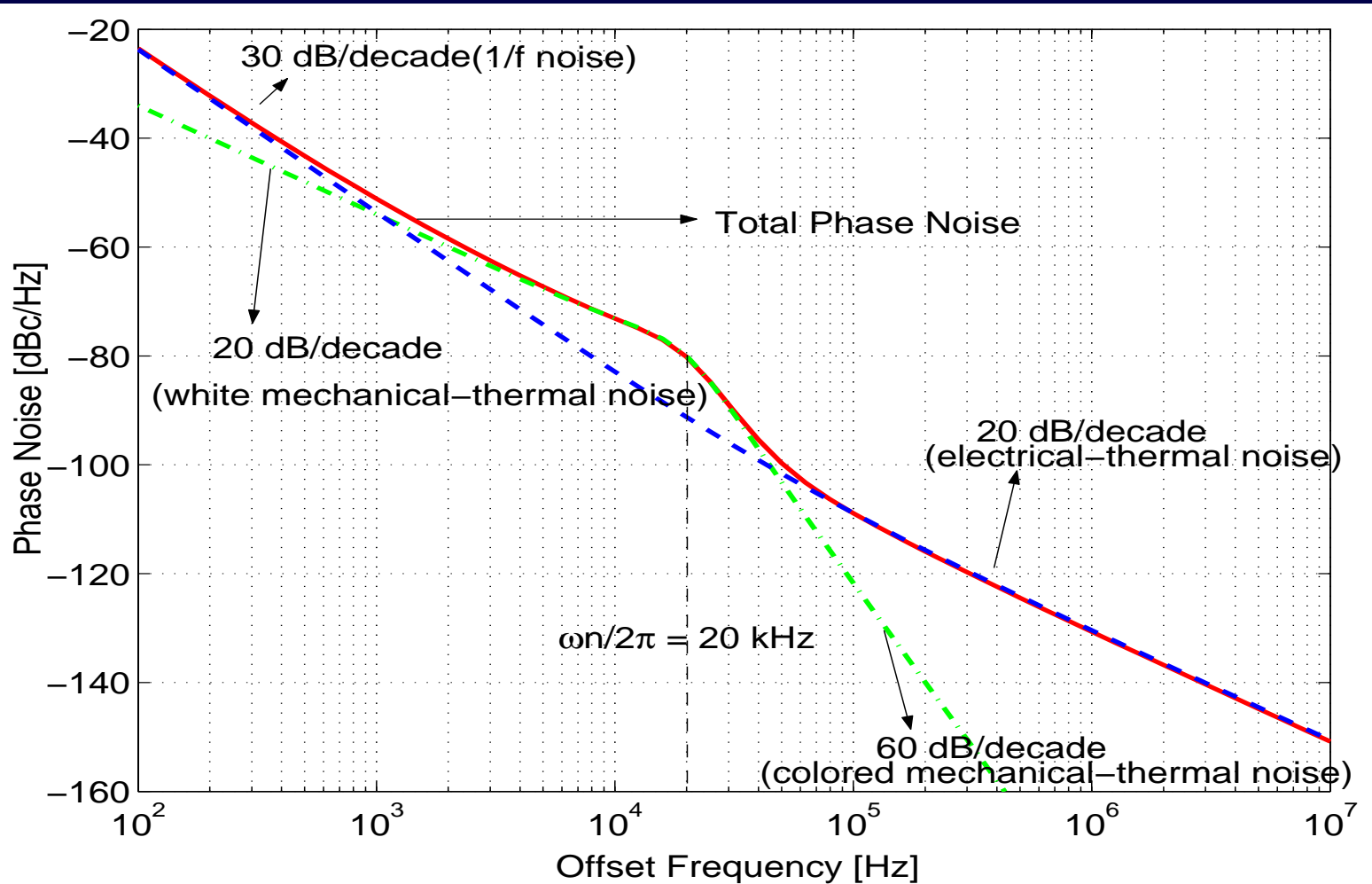
- HP 0.8 μm process



Noise Sources in RF MEMS VCOs

- **Electrical-thermal noise**
 - Due to thermal excitation of charge carriers
 - White power spectral density
- **Flicker noise**
 - $1/f$ noise
- **Mechanical-thermal noise (Brownian noise)**
 - Due to thermal vibration of suspended plates
 - White power spectral density for low offset frequencies and colored for higher frequencies

Simulated Phase Noise



Comparison with Measured Data

Offset Freq.	Measured [†] ($Q_M = 1$)	Simulated ($Q_M = 1$)	Simulated ($Q_M = 5$)	Simulated ($Q_M = 15$)
10 kHz	-----	-73.1	-77.6	-80.4
100 kHz	-110	-108.9	-109.1	-109.1
3 MHz	-139	-140.8	-140.8	-140.8

[†] D. J. Young, *Ph.D. Dissertation*, UC Berkeley, 1999.

Summary of SPICE3/EM8.9 Simulator

- **Coupled SPICE3/EM8.9 simulator used for accurate simulation of RF MEMS VCOs**
- **Simulated results show the effect of the mechanical quality factor on phase noise**

M. Behera, et al., "Accurate simulation of RF MEMS VCO performance including phase noise," *JMEMS*, April 2005.

Conclusions

- **Coupled circuit/device simulations**
 - Allow accurate simulation of circuits/systems
 - Provide direct link between technology changes and circuit performance
 - Useful for developing accurate compact models
- **Need faster solution methods for PDEs**
- **Different coupling algorithms need to be developed for various problem domains**

Acknowledgments

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